

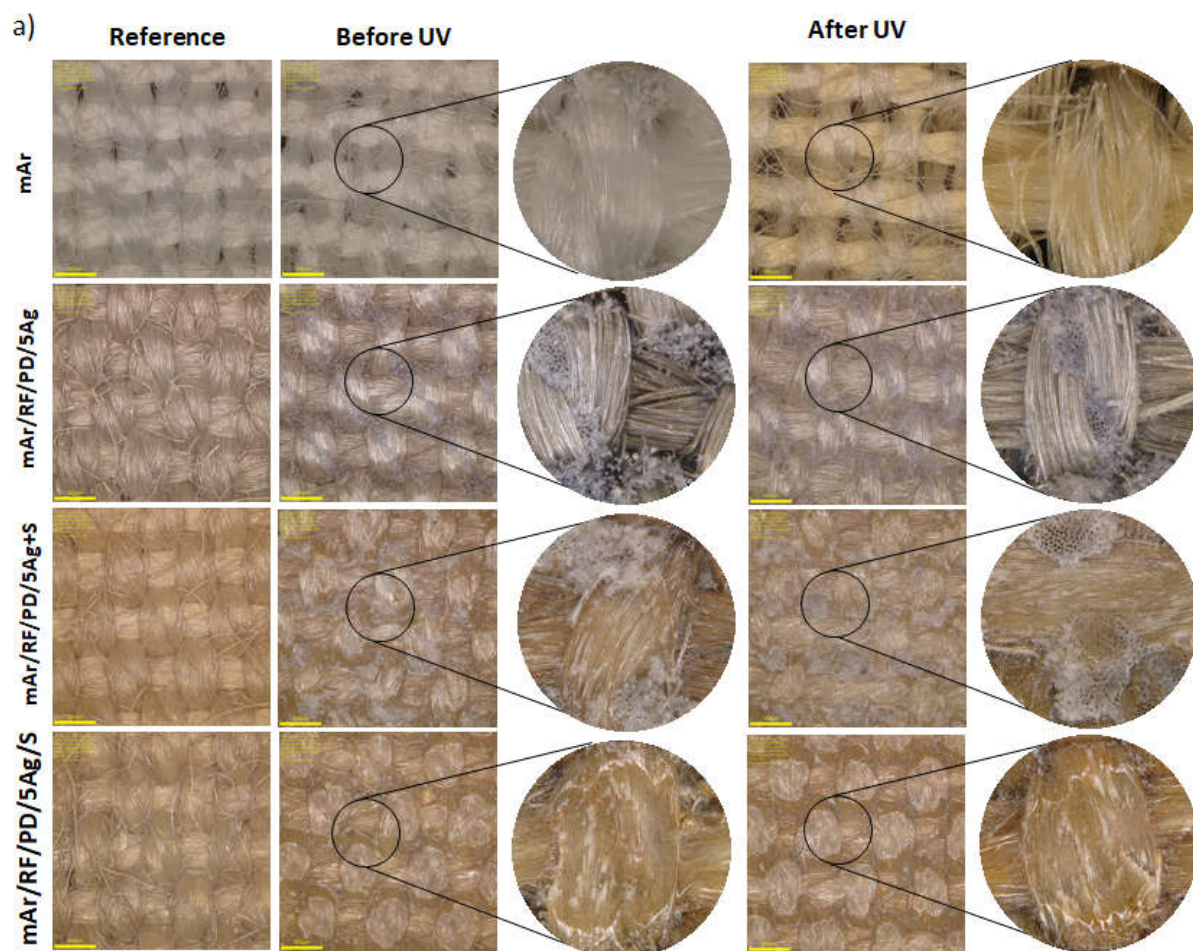
Supplementary Materials

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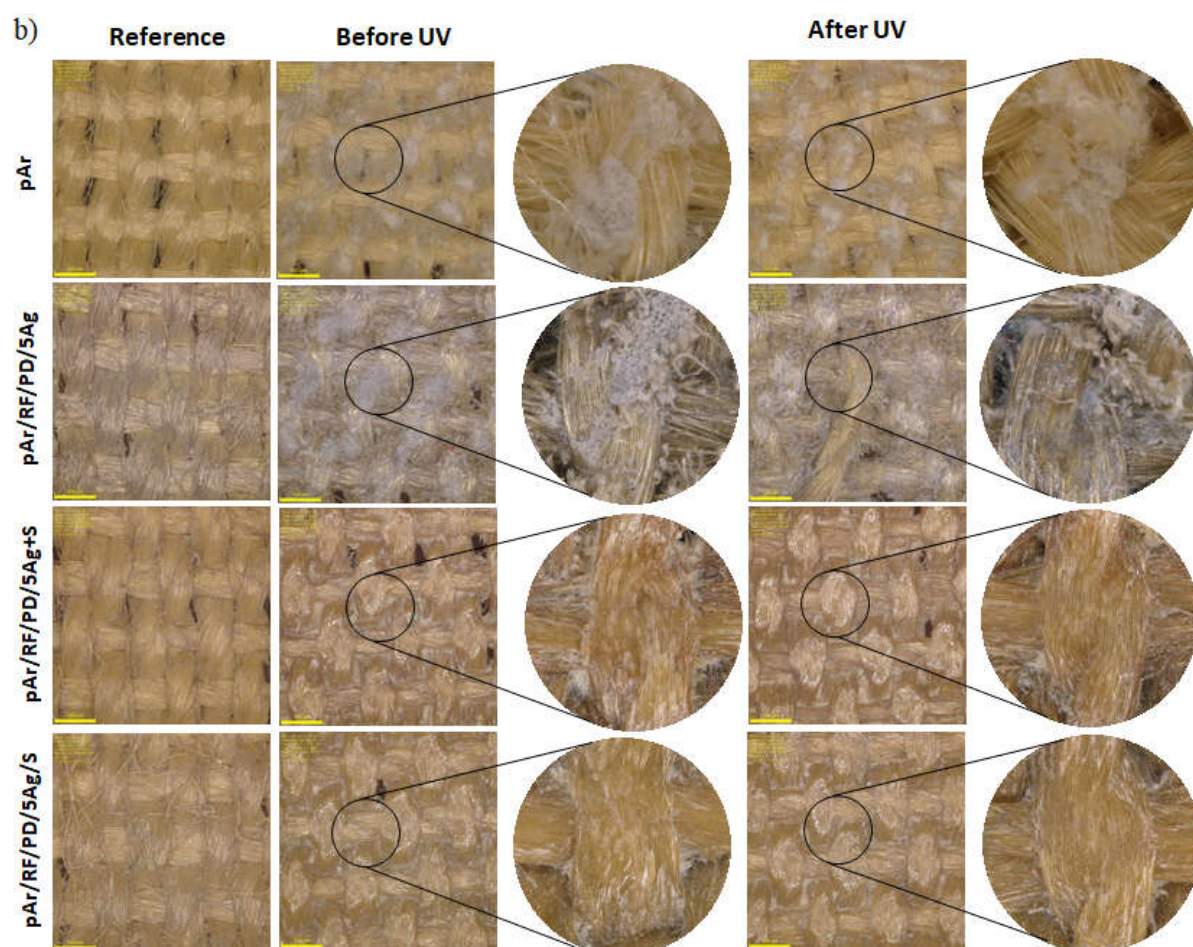


Figure S1. Images of (a) *m*Ar and (b) *p*Ar fabrics surfaces, before and after UV radiation (365 nm, 96 h), before and after abrasion cycles.